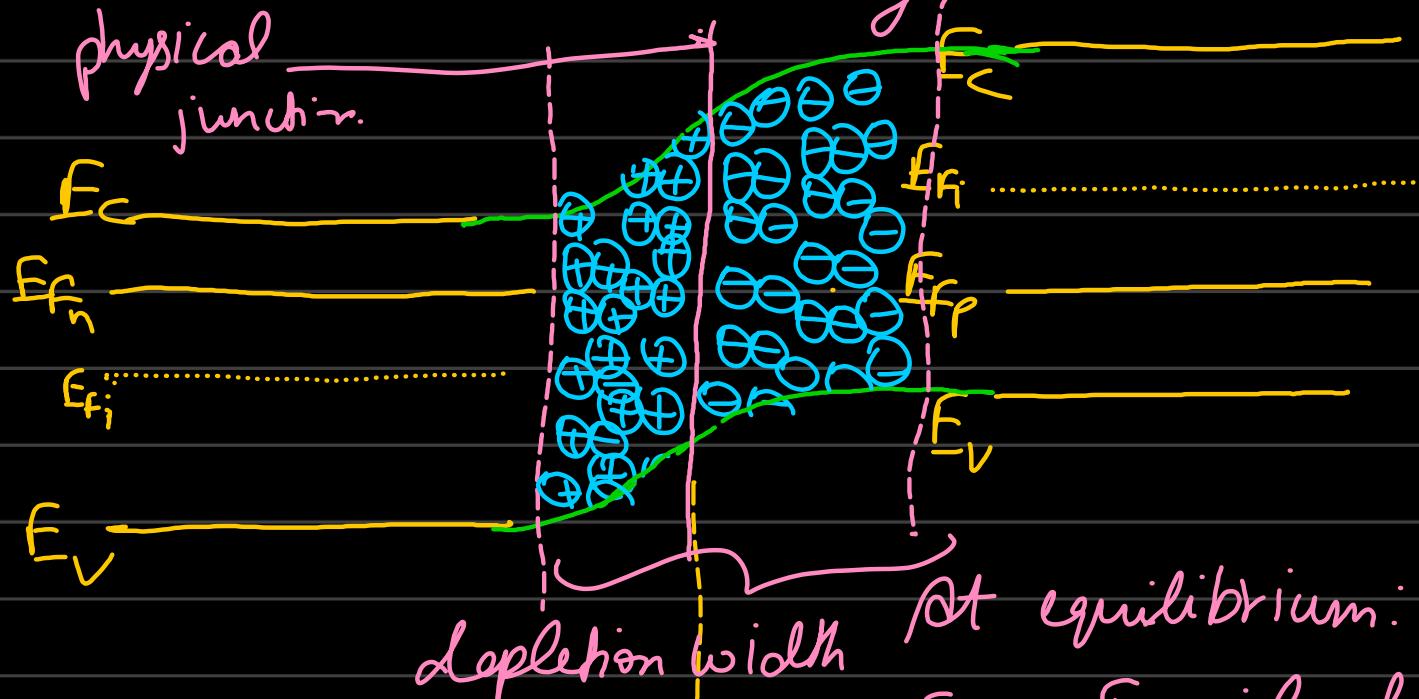


Lecture 1.9

Semiconducting Devices



At equilibrium:

$E_F \rightarrow$ Fermi level
is flat.
 $T=0$

$$n = N_c e^{-(E_F - E_F)/kT}$$

$$p = N_v e^{-(E_F - E_V)/kT}$$

Poisson's Equation: $-\nabla^2 \phi = \rho$

{Gauss Law}

$$-\nabla^2 V = \rho$$

$$-\frac{dV}{dx} = E \rightarrow \frac{dE}{dx} = \rho$$

charge density

enclosed.

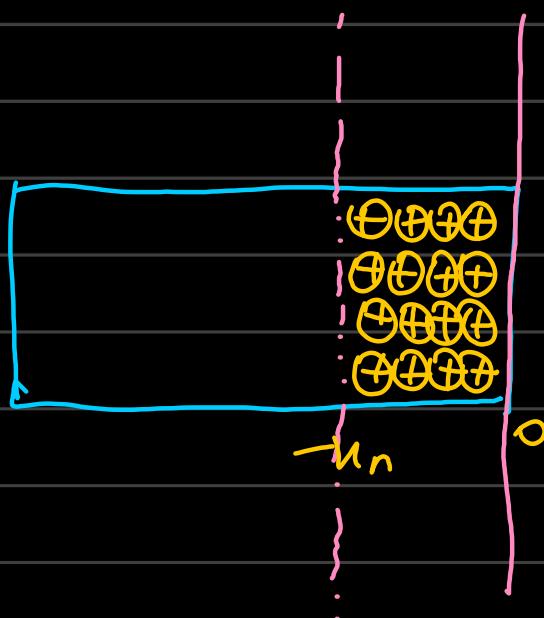
$\epsilon_0 = 1$ in vacuum \rightarrow Gauss Law

n - side : N_D^{\oplus} : no. of donors.

p - side : N_A^{\ominus} : total no. of acceptors.

$$\frac{dE}{dn} = q \left[p - n + N_D^{\oplus} - N_A^{\ominus} \right]$$

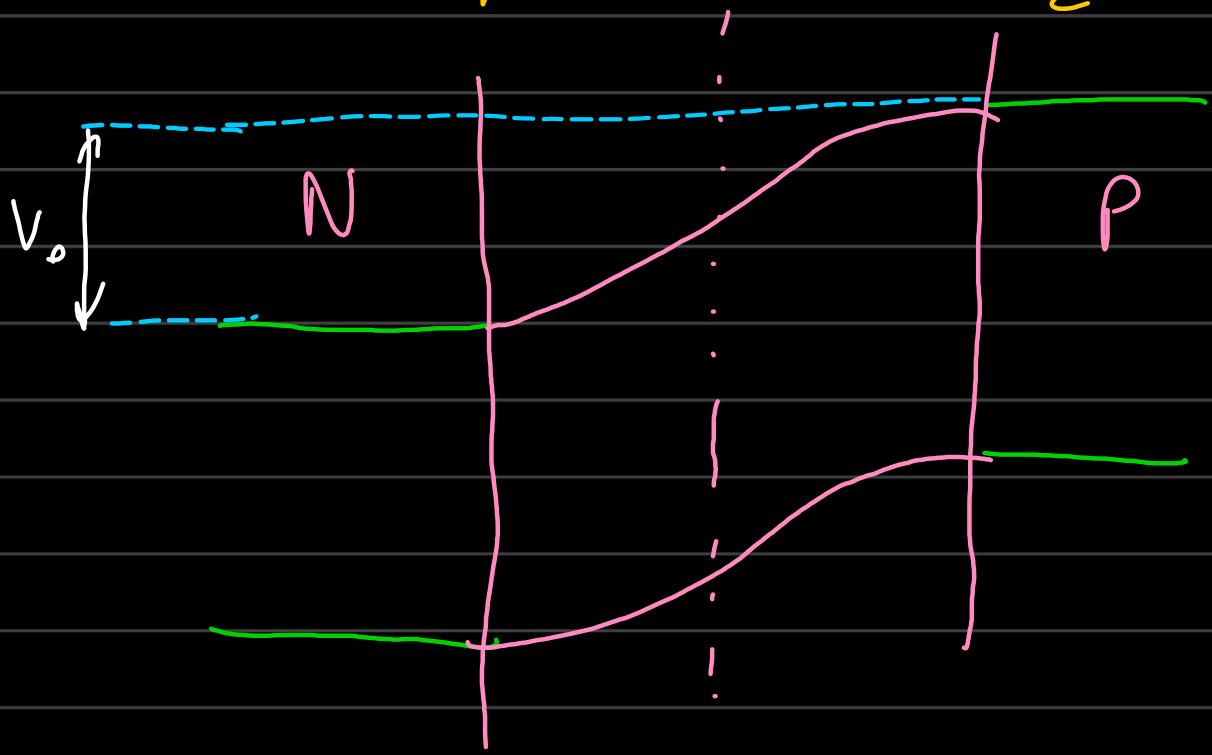
+ve charged
-ve charged

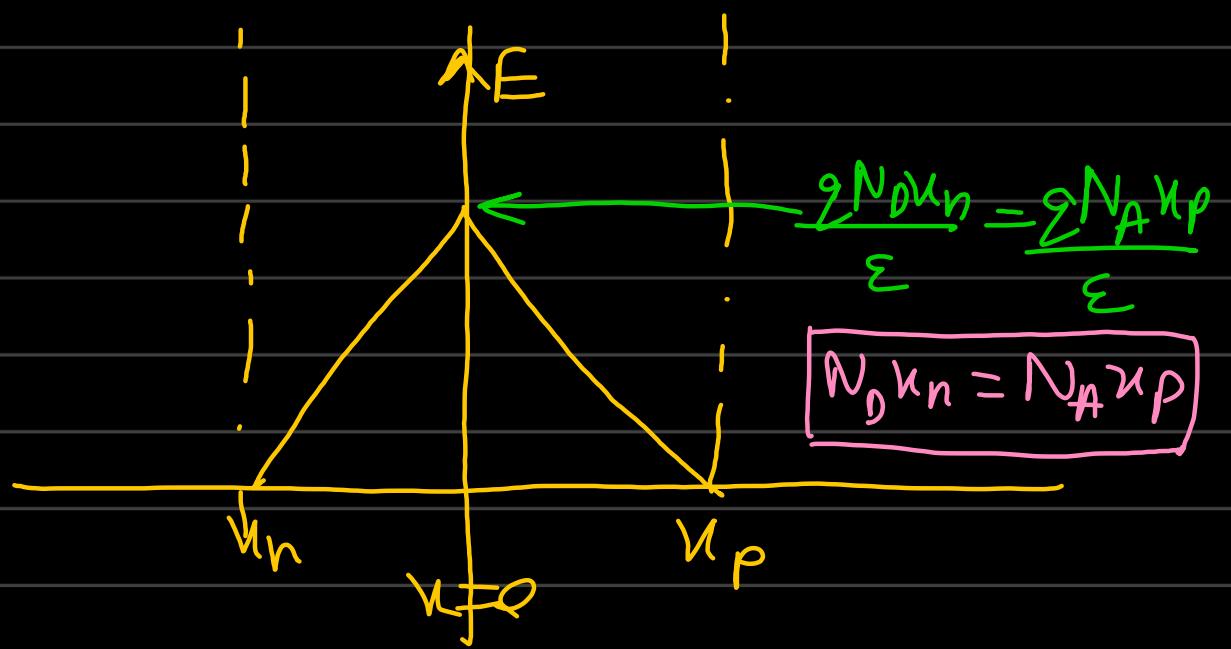


$$\frac{dE}{dn} = \frac{qN_D}{\epsilon}$$

$p=n=0$ {in depletion width}
 $N_A=0$ {n-type semi conductor}

$$E = \int_{n=0}^{n=0} \frac{qN_D}{\epsilon} dn = \frac{qN_D n_n}{\epsilon}$$





Built-in Potential

V_0 = area under curve

$$= \frac{1}{2} \times (k_p + k_n) \times E_{max}$$

$$\downarrow V_0 = \frac{(k_p + k_n)}{2} \frac{2N_D w_n}{\epsilon}$$

extent of band bending

$$V_0 = \frac{1}{2} \omega E_{max}$$

$$\omega = k_p + k_n$$

$$E_{max} = \frac{2N_D w_n}{\epsilon}$$

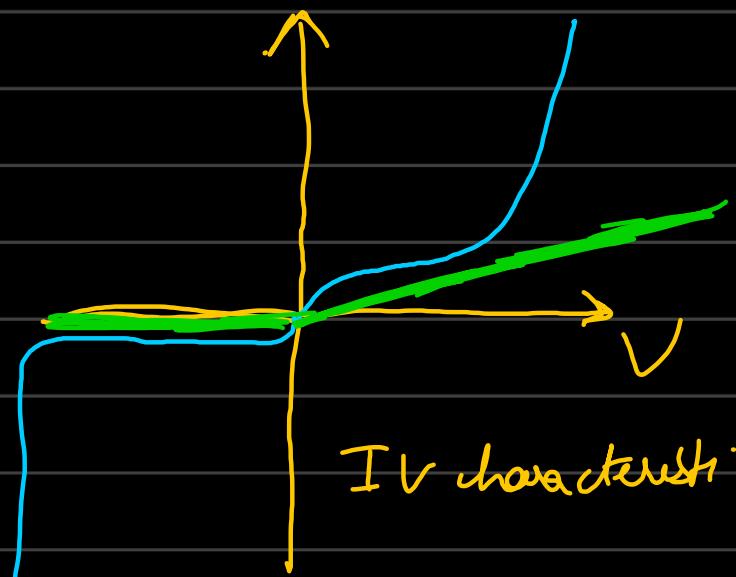
$$N_D w_n = N_A w_p$$

$$V_0 = \frac{\epsilon N_A N_D \omega^2}{2 \epsilon (N_A + N_D)}$$

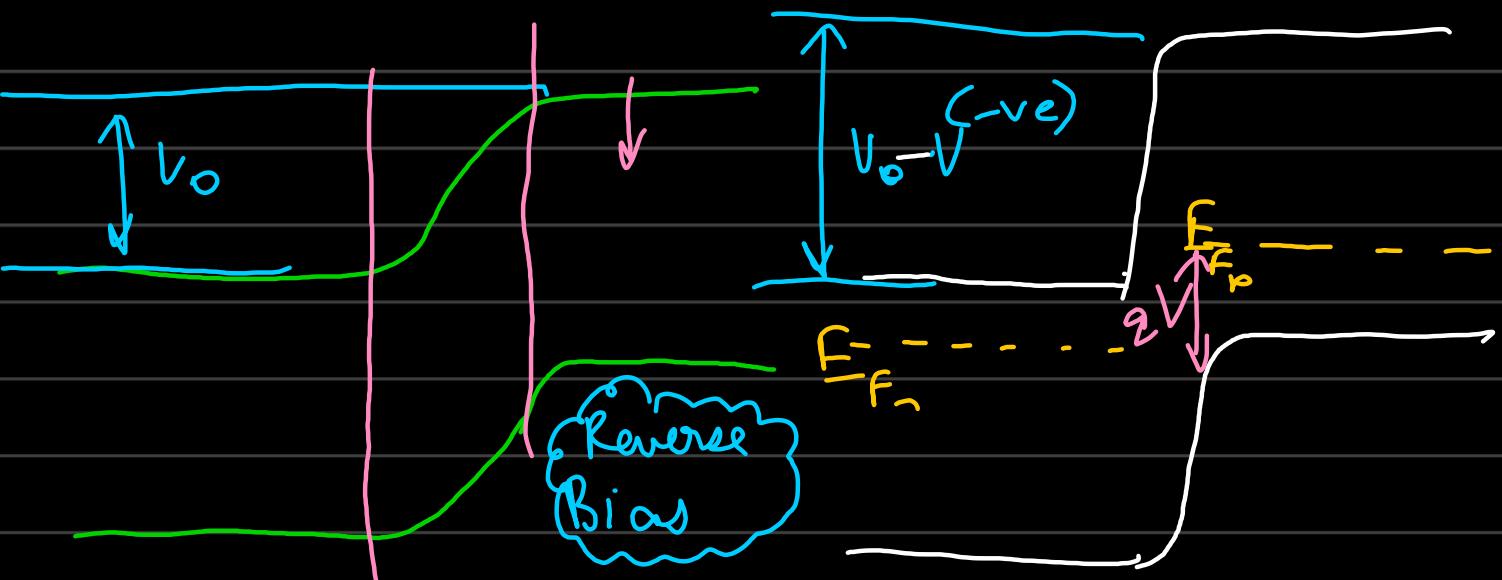
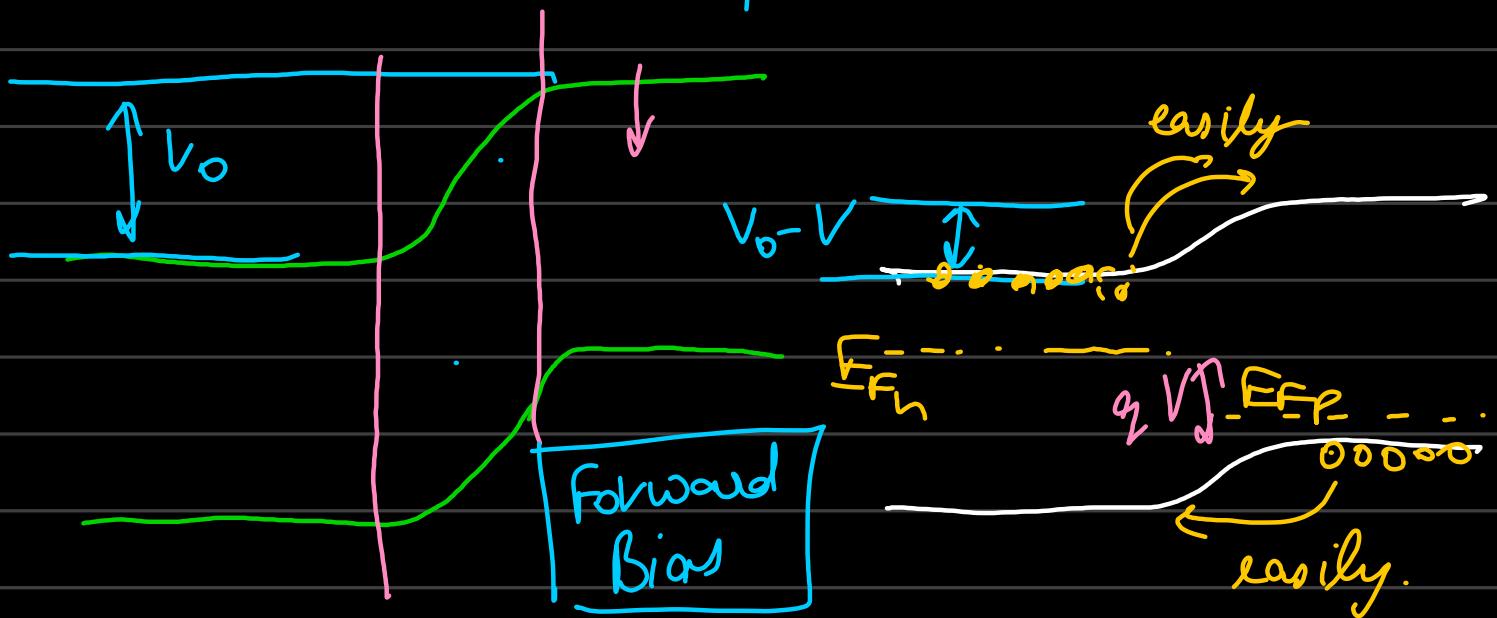
$$I = I_0 [e^{(\beta V)} - 1]$$

$$\beta = \frac{q}{kT}$$

due to diffusion



IV characteristics.



$$\text{for } J=0 : \frac{dE_F}{dn} \neq 0 \quad \frac{\Delta E_F}{\Delta n} \neq 0$$

during junction performance.

$$\phi = E_{vac} - E_{Fermi} \geq \text{work func}$$

$$\chi = E_{vac} - E_{conduction} = \text{electron affinity}$$